

CHOLLEY Post Stress Skin Repair Mask is an excellent soothing, normalizing, and hydrating product for face, neck, and décolleté. It relieves redness and discomfort of solar exposure, and helps speed the healing process. It is an ideal mask for professional treatment of stressed or damaged skin.

CHOLLEY Post Stress Skin Repair Mask may be used either as an anti-stress, replenishing mask or as a protective day cream. Its soothing decongestant action relieves solar irritations and diminishes the redness caused by dilated capillaries. The emollient-hydrating action of **CHOLLEY Post Stress Skin Repair Mask** gives the skin a smooth, supple, and harmonious look accompanied by a natural radiance.

An additional benefit of **CHOLLEY Post Stress Skin Repair Mask** is a better and longer-lasting suntan, thanks to its vigorous anti-oxidant properties, which make it an indispensable companion for summer and winter vacations.

Performance characteristics & active ingredients

CHOLLEY Post Stress Skin Repair Mask performs important dermatological functions as follows:

- **Soothing, decongestant, and normalizing action to relieve irritation/redness**

BETA-GLUCAN
AZELAMIDE MEA
POTENTILLA ERECTA ROOT EXTRACT
CHAMOMILLA RECUTITA FLOWER EXTRACT

- **Anti-wrinkle and anti-oxidant actions**

RETINYL PALMITATE (Vitamin A)
ASCORBYL PALMITATE
TOCOPHEROL (Vitamin E)

- **Emollient and hydrating action**

PPG-3 MYRISTYL ETHER
HELIANTHUS ANNUUS SEED OIL
ARACHIS HYPOGAEA (Peanut oil)
SORBITOL
GLYCERIN

- **Non parabenic conservation**

BENZYL ALCOHOL
DEHYDROACETIC ACID
SODIUM BENZOATE

Recommended use

CHOLLEY Post Stress Skin Repair Mask is recommended after sun tanning, skiing, or any other prolonged solar exposure. It is also very beneficial in soothing and normalizing the skin after a stress (physical, environmental, or psychological). It can be used in treatment of acne scars and acne rosacea.

Application

Apply a rich layer of **CHOLLEY Post Stress Skin Repair Mask** on clean face, neck, and décolleté. Let it rest for 10 to 15 minutes before removing it with a lukewarm compress. Complete the treatment with the application of **CHOLLEY PHYTOBIOTECH Skin Repair Complex**.

Ingredients:

AQUA, STEARIC ACID, GLYCERIN, PPG-3 MYRISTYL ETHER, SORBITOL, SODIUM CETEARYL SULFATE, POTASSIUM CETYL PHOSPHATE, HELIANTHUS ANNUUS SEED OIL, CETYL ALCOHOL, AZELAMIDE MEA, GLYCERYL STEARATE, BENZYL ALCOHOL, HYDROGENATED C12-18 TRIGLYCERIDES, CI 77491, PARFUM, JUGLANS REGIA SHELL EXTRACT, ALCOHOL, TOCOPHEROL, ASCORBYL PALMITATE, DEHYDROACETIC ACID, RETINYL PALMITATE, POTENTILLA ERECTA ROOT EXTRACT, ARACHIS HYPOGAEA OIL, BETA-GLUCAN, CHAMOMILLA RECUTITA FLOWER EXTRACT, GLUCONOLACTONE, SODIUM BENZOATE, RUTIN, CALCIUM GLUCONATE.

Packaging:

Available in retail and professional version



CHOLLEY
Post Stress Skin Repair Mask

Ref. 735V
50 ml

Ref. 735K
150 ml